WHEN:
June 19–24, 2016

WHERE:
The Fletcher School of Law and Diplomacy, Tufts University, near Boston, Massachusetts (USA)

WHO SHOULD APPLY:
International professionals, civil society leaders, journalists, grassroots organizers, policy analysts, scholars and educators.

TOPICS COVERED INCLUDE:
• How civil resistance works
• Why civil resistance campaigns succeed or fail
• Civil resistance strategy and tactics
• Movement and campaign communications and media
• Case studies of movements and campaigns from around the world
• How civil resistance shapes societies, national, and international affairs

“I’ve been so impressed with the strength, power and courage of people that I’ve met. It … feeds your soul just being here for five days.” —Espen Goffeng, FSI ’13

The Fletcher Summer Institute for the Advanced Study of Nonviolent Conflict (FSI) is the leading professional education program in the world focusing on the advanced, interdisciplinary study of civil resistance.

Civil resistance campaigns for rights, freedom, and justice are capturing the world’s attention as never before. Campaigns against corruption in Guatemala, Moldova, and Cambodia; against dictatorship in Burkina Faso; to protect democracy in Hong Kong; for police accountability in the United States; for indigenous rights in Latin America; and for women’s rights in India are all examples in recent years of a profound global shift in how political power is developed and applied.

Since 2006, more than 450 participants from nearly 100 countries have gathered at FSI to learn and share knowledge. The program is taught by leading international scholars, practitioners, organizers and activists from past and current struggles. It provides both a firm academic grasp of the subject of civil resistance as well as a practical understanding of the use of nonviolent struggle in a variety of conflicts for a wide range of goals.

Organized by the International Center on Nonviolent Conflict (ICNC), in conjunction with the Fletcher School of Law and Diplomacy at Tufts University.

Application Deadline:
January 3, 2016

For more information, visit: